

iPlasmanano V. 2014 Program



<http://www.barcelocongresos.com.es/iPlasmaNano-V/>

Keynotes: 30 min including questions (25+5 min)

Regular talks: 20 min including questions (17+3 min)

Sunday 28-Sept			
17.00-19.00		Reception-registration	
19.00	Dinner		

Monday 29-Sept			
8.30-8.40		Opening	A. Barranco and K. Ostrikov
8.40-8.50			K. Ostrikov: Entrepreneuring plasma-nano in the hurricane of change: challenge – risk – collaboration – agility – value
Session M1 –Nanostructures (Chairman: E. Neyts)			
8.50-9.20		M1-1 Keynote-1	M. Sankaran: Controlling gas-phase nucleation via microplasma processes for the synthesis of novel nanoparticle materials
9.20-9.40		M1-2	U. Cvelbar: Underlying mechanisms of copper oxide nanowire growth
9.40-10.00		M1-3	O. Polonskyi: Nanoparticles and Nanocomposite Thin Films Prepared by Gas Aggregation Source
10.00-10.20		M1-4	M. Sunkara: Plasma processes for scalable production of nanowire based materials
10.20-10.40		M1-5	H. Ying Yang: Synthesis 2D materials by Chemical Vapor Deposition method
10.40-11.10	Coffee break		
Session M2– Graphene, carbon and organic materials I (Chairman: J. Zheng)			
11.10-11.30		M2-1	E. Tatarova: Microwave Plasmas Applied for Synthesis of Free Standing Graphene Sheets
11.30-11.50		M2-2	K.H. Chen: Electrochemical and Supercapacitor Applications of Microwave CVD grown Graphene Nanowalls
11.50-12.10		M2-3	S. Mao: Vertically-oriented Graphene for Environmental Applications: Biosensors and Gas sensors
12.10-12.30		M2-4	J. Henriques: Surface Wave Discharges Applied for Carbon Nanostructures Assembly
12.30-12.50		M2-5	K.I Bystrov: Spontaneous synthesis of carbon nanostructures under extreme plasma fluxes
13.30-15.00	Lunch		
Session M3–Inorganic materials I (Chairman: Y. Raitses)			
15.00-15.30		M3-1 Keynote-2	J. P. Allain: Self-organization and nano-patterning of III-V semiconductor systems by directed irradiation synthesis
15.30-15.50		M3-2	I. Tanyeli: Nanostructuring of metal surfaces by low energy helium ions
15.50-16.10		M3-3	D. Ruzic: The Formation of Nano-Fuzz in Tungsten
16.10-16.30		M3-4	M. Gordon: Microplasma Spray Deposition of Nanostructured Films for Catalytic, Magnetic, and Energy Applications
16.30-16.50		M3-5	G. Wu: Design and Fabrication of Temporary Surface on Biodegradable Magnesium Alloys Based on Plasma and Ion Beam Techniques

16.50-17.10	Coffee break	
Session M4–Graphene, carbon and organic materials II (Chairman: T. Gries)		
17.10-17.30	M4-1 E. Bertran: Carbon Nanotubes structural evolution during water assisted plasma growth	
17.30-17.50	M4-2 G. Dinescu: Control of application-related properties of carbon nanowalls synthesized by a plasma jet	
17.50-18.10	M4-3 W. J. Zhang: Surface nanostructures of diamond and cubic boron nitride films by reactive ion etching.	
19.00	Dinner	

Tuesday 30-Sept

Session T1– Inorganic Materials II-Silicon (Chairman: S. Xiao)

8.30-9.00		T1-1 Keynote-3	L.C. Chen: Si nanotips produced by ECR plasma-enhanced CVD and their hybrids: from antireflection to plasmon management
9.00-9.20		T1-2	E. Gogolides: Polymeric and Silicon nanowire arrays by plasma nanotexturing and plasma etching. How tall can they get before bundling?
9.20-9.40		T1-3	H. Vach: Coherent Gigahertz and Terahertz Emission from Plasma-born Aromatic Silicon Nanocrystals
9.40-10.00		T1-4	V. Svrcek: Advanced plasma technologies towards direct-bandgap silicon
10.00-10.20		T1-5	J. Benedikt: Atmospheric Pressure Microplasma Jets for the Generation of Silicon Nanoparticles
10.20-10.40		Coffee break	

Session M2–Plasma discharges (Pulsed laser, atmospheric, etc.) (Chairman: I. Tamyeli)

10.40-11.10		M2-1 Keynote-4	M. Chaker: Nanomaterials and thin film synthesis based on pulsed laser deposition
11.10-11.30		M2-2	J. Lunney: Pulsed laser deposition of metal nanoparticle films
11.30-11.50		M2-3	F. do Nascimento: A new compact atmospheric pressure plasma for processing of materials
11.50-12.10		T2-4	Y. Raitses: Synergy of Plasma and Material Processes in Atmospheric Pressure Carbon Arcs
12.10-12.30		T2-5	T. Gries: Alkali-assisted growth of metal oxide nanowires by atmospheric pressure microwave afterglow
12.30-12.50		T2-6	A. Bogaerts: Plasma conversion of greenhouse gases in value-added chemicals: a modeling point of view
13.30-15.00		Lunch	

Session M3– Graphene, carbon and organic materials III-Biomaterials (Chairman: K. Bystrov)

15.00-15.30		T3-1 Keynote-5	G. Amaratunga: Plasma deposited carbon nanotube arrays for photonics
15.30-15.50		T3-2	Endre Szili: Following the plasma delivery of reactive oxygen species into synthetic tissue and cell models
15.50-16.10		T3-3	T. Kaneko: Physical and Chemical Effects of Helium Plasma Jet on Gene Transfection Efficiency
16.10-16.30		T3-4	K. Vasilev: Nanoengineered plasma polymer films for biomaterial applications
16.30-16.50		T3-5	J.M. Martín-Martínez: Incidence of surface treatment of polymers with atmospheric and low-pressure plasmas on adhesion : Incidence on biomedical applications
16.50-17.10		Coffee break	
19.00		Dinner	16

Wednesday 1-Oct.**Session W1—Title Plasma Discharges (Chairman: R. di Mundo)**

8.30-9.00		W1-1 Keynote-6	A. Ng: Nanoplasma in Warm Dense Matter research
9.00-9.30		W1-2 Keynote-7	M. Hori: Radical-Controlled Plasma Nanoprocesses towards Global Innovations
9.30-9.50		W1-3	D. Go: Electron-initiated interactions at the interface of plasmas and liquids
9.50-10.10		W1-4	T. Belmonte: Synthesis of nanoparticles of aluminium by spark discharges in liquid nitrogen, water and heptane: a comparative study.
10.10-10.30	Coffee break		

Session M2—Applications I (Chairman: S. Mao)

10.30-11.00		W2-1 Keynote-8	R. Hatakeyama: Novel-Concept Solar Cell Using Plasma-Functionalized SWNTs Thin Films
11.00-11.20		W2-2	J. Zheng: Binary nanocomposites by plasma processing and their applications in energy storage
11.20-11.40		W2-3	D. Mariotti: Nanoscience to nanotechnology: the role of atmospheric pressure plasmas in photovoltaics
11.40-12.00		W2-4	S. Xiao: Low-temperature plasma processing for Si photovoltaics
12.00-12.20		W2-5	S. Coulombe: Plasma-assisted synthesis of nanomaterials and nanostructures for energy applications
12.20-12.40		W2-6	J. Margot: Plasma patterning of advanced oxides: achievements and applications to photonics

12.40- **iPlasmanano business meeting**

13.30-15.00	Lunch	11
17.00	Social visit, coast panoramic, etc.	
21:00	Conference Dinner	

Thursday 2-Oct.**Session M1—Fundamentals (Chairman: F. Reniers)**

9.00-9.30		Th1-1 Keynote-9	T. Fennel: Ultrafast nanoplasma dynamics in clusters
9.30-9.50		Th1-2	H. Kersten: Correlation of nanoparticle growth with discharge parameters for a novel particle collection concept
9.50-10.10		Th1-3	E. Neyts: Nanoscale Perspectives on Plasma Catalysis
10.10-10.30		Th1-4	G. Kokkoris: Investigation of nanoscale roughening of plasma treated surfaces by a multiscale modeling framework
10.30-10.50	Coffee break (hotel check-out)		

Session M2—Applications II (Chairman: E. Tatarova)

10.50-11.10		Th2-1	F. Reniers: Atmospheric pressure plasma synthesis of metal nanoparticles
11.10-11.30		Th2-2	H. Puliyaill: Improving the vapor detection properties of polyaniline composites by plasma surface modifications
11.30-11.50		Th2-3	R. Di Mundo: Assessing fakir state robustness of superhydrophobic plasma generated randomly nano-rough surfaces
11.50-12.10		Th2-4	M. Jacob: RF Plasma polymerised thin films from natural precursors
12.10-12.30		Conference closing. Chair: A. Barranco and K. Ostrikov iPlasmanano VI	
13.20-15.00	Box lunch and departure		

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